NFORMATION DISCLOSURE CITATION
- IN AN APPLICATION (Use several sheets if necessary)

	Sheet I of I							
Docket Number (Optional)	Application Number							
SAM-0313	10/081,661							
Applicant Soo-geun Lee, et al.								
Filing Date	Group Art Unit							

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1	- AB	- 6-EEO-E2O-	- :E/E/O3: ::	Maeeviki-e		257	- 642	7/12	5/02		
	AC	- 6,559,520	5/6/03	Matsuki, e	-			4/6/01			
		6,514,880	2/4/03	Matsuki, e		438	780	3/28/01 10/18/00 10/18/00 6/7/99			
	AD	6,455,445	9/24/02	Matsuk		438	789				
	AE	6,432,846	8/13/02	Matsuk	(1	438	790				
	AF	6,410,463	6/25/02	Matsuk	i	438	790				
	AG	6,383,955	5/7/02	Matsuki, e	t al.	438	790				
	AH	6,352,945	3/5/02	Matsuki, e	tal.	438	778	6/7/99			
	Al	6,057,239	5/2/00	Wang, et	al.	438	689	12/17/97			
4	AJ	01/0046778	11/29/01	Wang, et	al.	H01L	21/302	3/22/00			
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	OTHER	DOCUMEN	ITS (Inclu	iding Author	, Title, D	ate, P	ertinent	Pages	s, Etc		
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through cit	ation if no	if citation consider	red, whether and not consi	or not citation is in dered. Include cop	conformance	e with M ommuni	PEP § 609;	plicant.			